6348/ETCH/SILICON

To the Honorable Commissioner of Patents and Trademarks: Please record	the attached original document or copy thereof.
1. Name of conveying party(ies): Keiji Horioka 94-15-02 Douglas H. Burns 05-14-02 Chun Yan 94-11-02 Evans V. Lee 05-01-02	2. Name and address of receiving party(ies):
Chun Yan 04-11-02 Evans Y. Lee 05-01-02 Taeho Shin 04-37-02 Bryan Y. Pu 04-14-02	Name: Applied Materials, Inc,
Roger Alan Lindley ウリール のえ。 Qi Li のそのも シュ	Internal Address:
Panyin Hughes 04 - 16 - 02	
Additional name(s) of conveying party(ies) attached?YesX_No	Street Address: 3050 Bowers Avenue
3. Nature of conveyance:	
X AssignmentMerger	P.O. Box 450A
Security Agreement Change of Name	City: Santa Clara State: CA Zip: 95054
Other	Additional name(s) & address(es) attached? Yes _X_ No
Execution Date: SEE ABOVE	
4. Application number(s) or registration number(s):	<u>.</u>
If this document is being filed together with a new application, the execut	tion date of the application is: Much 14, 2002 (Date of Filing)
A. Patent Application No.(s)	\mathcal{U}
A. Patent Application No.(s)	
	10/146443
A. Patent Application No.(s) B. Patent No.(s) Additional numbers attached?Yes X_No	10/14/443
A. Patent Application No.(s) B. Patent No.(s)	6. Total number of applications and patents involved:
A. Patent Application No.(s) B. Patent No.(s) Additional numbers attached?Yes _X_ No 5. Name and address of party to whom correspondence concerning	10/14/443
A. Patent Application No.(s) B. Patent No.(s) Additional numbers attached?Yes _X_ No 5. Name and address of party to whom correspondence concerning document should be mailed: Name: Patent Counsel	6. Total number of applications and patents involved: 7. Total fee (37 C.F.R. 3.41)
A. Patent Application No.(s) B. Patent No.(s) Additional numbers attached?Yes _X_No 5. Name and address of party to whom correspondence concerning document should be mailed:	6. Total number of applications and patents involved:
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A. Patent Application No.(s) B. Patent No.(s) Additional numbers attached?Yes X_No 5. Name and address of party to whom correspondence concerning document should be mailed: Name:Patent Counsel Internal Address:APPLIED MATERIALS, INC. Street Address: _P.O. Box 450A City: Santa ClaraState: _CAZip: 95052 2002 6TOH11 00000152 501074 10146443	6. Total number of applications and patents involved: 7. Total fee (37 C.F.R. 3.41)
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A. Patent Application No.(s) B. Patent No.(s) Additional numbers attached?Yes X_No 5. Name and address of party to whom correspondence concerning document should be mailed: Name:Patent Counsel Internal Address:APPLIED MATERIALS, INC. Street Address: _P.O. Box 450A City: Santa Clara State: _CA Zip: 95052 2002 GTUH11 00000152 501074 10146443 DO NOT 581 40.00 CH 9. Statement and signature.	6. Total number of applications and patents involved: 7. Total fee (37 C.F.R. 3.41) Enclosed X Authorized to be charged to deposit account 50-1074 8. Deposit account number: 50-1074

Mail documents to be recorded with required cover sheet information to:

Commissioner of Patents & Trademarks, Box Assignments

Washington, D.C. 20231

Names and Addresses of Inventors:

1) Keiji Horioka	6)	Panyin Hughes
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2) Chun Yan 7) Douglas H. Burns

3) Taeho Shin 8) Evans Y. Lee

4) Roger Alan Lindley 9) Bryan Y. Pu

5) Qi Li

(hereinafter referred to as Assignors), have invented a certain invention entitled:

METHOD AND APPARATUS FOR CONTROLLING THE MAGNETIC FIELD INTENSITY IN A PLASMA ENHANCED SEMICONDUCTOR WAFER PROCESSING CHAMBER

for which application for Letters Patent in the United States was executed on even date herewith; and

WHEREAS, Applied Materials, Inc., a corporation of the State of Delaware, having a place of business at 3050 Bowers Avenue, Santa Clara, California 95054 (hereinafter referred to as Assignee), is desirous of acquiring the entire right, title and interest in and to said application (hereinafter referred to as Application), and the invention disclosed therein (hereinafter referred to as Invention), and in and to all embodiments of the Invention, heretofore conceived, made or discovered by said Assignors, and in and to any and all patents, inventor's certificates and other forms of protection (hereinafter referred to as Patents) thereon granted in any and all countries and groups of countries.

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1 of 2

PATENT REEL: 012924 FRAME: 0193

- 3. The term and covenants of this agreement shall inure to the benefit of said Assignee, its successors, assigns and other legal representatives, and shall be binding upon said Assignors, their respective heirs, legal representatives and assigns.
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1)	Apr 15, 2002	This I fole Keiji Horioka
2)	, 2002	Chun Yan
3)	, 2002	Taeho Shin
4)	, 2002	Roger Alan Lindley
5)	, 2002	Qi Li
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7)	, 2002	Douglas H. Burns
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9)	, 2002	Bryan Y. Pu

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2)	April 11	. 2002	Chun Yan
3)		, 2002	Taeho Shin
4)		, 2002	Roger Alan Lindley
5)		, 2002	Qi Li
6)		, 2002	Panyin Hughes
7)		, 2002	Douglas H. Burns
8)		, 2002	Evans Y. Lee
9)		_, 2002	Bryan Y. Pu

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2)	Chun Yan	7)	Douglas H. Burns
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PATENT REEL: 012924 FRAME: 0197

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1)	, 2002	Keiji Horioka
2)	, 2002	Chun Yan
3)	Apr: 18, 2002	Taeho Shin
4)	, 2002	Roger Alan Lindley
5)	, 2002	Qi Li
6)	, 2002	Panyin Hughes
7)	, 2002	Douglas H. Burns
8)	, 2002	Evans Y. Lee
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1)	, 2002	Keiji Horioka
2)	, 2002	Chun Yan
3)	, 2002	Taeho Shin
4)	4/16/02,2002	Roger Alah Lindley
5)	, 2002	Qi Li
6)	, 2002	Panyin Hughes
7)	, 2002	Douglas H. Burns
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Roger Alan Lindley

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PATENT REEL: 012924 FRAME: 0203

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6)	APRIL 16	, 2002	Panyin Hughes
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ASSIGNMENT FOR APPLICATION FOR PATENT

WHEREAS:

Names and Addresses of Inventors	Names	and	Addresses	of	Inventors:
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- 1. Said Assignors hereby sell, assign, transfer and convey to Assignee the full and exclusive right, title and interest (a) in and to said Application and said Invention; (b) in and to all rights to apply for patents on said Invention in any and all countries pursuant to the International Convention for the Protection of Industrial Property or otherwise; (c) in and to any and all Applications filed and any and all Patents granted on said Invention in any and all countries and groups of countries, including each and every Application filed and each and every Patent granted on any application which is a division, substitution, or continuation of said Application; and (d) in and to each and every reissue or extension of any of said Patents.
- 2. Said Assignors hereby covenant and agree to cooperate with said Assignee to enable said Assignee to enjoy to the fullest extent the right, title and interest to said Invention herein conveyed in any and all countries and groups of countries. Such cooperation by said Assignors shall include prompt production of pertinent facts and documents, giving testimony, execution of petitions, oaths, specifications, declarations or other papers, and other assistance all to the extent deemed necessary or desirable by said Assignee (a) for perfecting in said Assignee the right, title and interest herein conveyed; (b) for prosecuting any of said applications; (c) for filing and prosecuting substitute, divisional, continuing or

- 3. The term and covenants of this agreement shall inure to the benefit of said Assignee, its successors, assigns and other legal representatives, and shall be binding upon said Assignors, their respective heirs, legal representatives and assigns.
- 4. Said Assignors hereby warrant and represent that they have not entered and will not enter into any assignment, contract, or understanding in conflict herewith.

1)		, 2002	Keiji Horioka
2)		, 2002	Chun Yan
3)		, 2002	Taeho Shin
4)		, 2002	Roger Alan Lindley
5)		, 2002	Qi Li
6)		, 2002	Panyin Hughes
7)		, 2002	Douglas H. Burns
8)	5//	, 2002	Evans Y. Lee
9)		, 2002	Bryan Y. Pu

Names and Addresses of Inventors:

1) Keiji Horioka	6)	Panyin Hughes
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- 2) Chun Yan 7) Douglas H. Burns
- 3) Taeho Shin 8) Evans Y. Lee
- 4) Roger Alan Lindley 9) Bryan Y. Pu
- 5) Qi Li

(hereinafter referred to as Assignors), have invented a certain invention entitled:

METHOD AND APPARATUS FOR CONTROLLING THE MAGNETIC FIELD INTENSITY IN A PLASMA ENHANCED SEMICONDUCTOR WAFER PROCESSING CHAMBER

for which application for Letters Patent in the United States was executed on even date herewith; and

WHEREAS, Applied Materials, Inc., a corporation of the State of Delaware, having a place of business at 3050 Bowers Avenue, Santa Clara, California 95054 (hereinafter referred to as Assignee), is desirous of acquiring the entire right, title and interest in and to said application (hereinafter referred to as Application), and the invention disclosed therein (hereinafter referred to as Invention), and in and to all embodiments of the Invention, heretofore conceived, made or discovered by said Assignors, and in and to any and all patents, inventor's certificates and other forms of protection (hereinafter referred to as Patents) thereon granted in any and all countries and groups of countries.

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- 3. The term and covenants of this agreement shall inure to the benefit of said Assignee, its successors, assigns and other legal representatives, and shall be binding upon said Assignors, their respective heirs, legal representatives and assigns.
- 4. Said Assignors hereby warrant and represent that they have not entered and will not enter into any assignment, contract, or understanding in conflict herewith.

IN WITNESS WHEREOF, the said Assignors have executed and delivered this instrument to said Assignee on the dates indicated below.

1)	, 2002	Keiji Horioka
2)	, 2002	Chun Yan
3)	, 2002	Taeho Shin
4)	, 2002	Roger Alan Lindley
5)	, 2002	Qi Li
6)	, 2002	Panyin Hughes
7)	, 2002	Douglas H. Burns
8)	, 2002	Evans Y. Lee
9)	4-14-02, 2002	Bejan Mr. Bryan Y. Pu